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A New Thermoelectric Material: CsBi₄Te₆

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Abstract: The highly anisotropic material CsBi₄Te₆ was prepared by the reaction of Cs/Bi₂Te₃ around 600 °C. The compound crystallizes in the monoclinic space group C2/m with a = 51.9205(8) Å, b = 4.4025(1)Å, c = 14.5118(3) Å, β = 101.480(1)°, V = 3250.75(11) Å³, and Z = 8. The final R values are R_1 = 0.0585 and wR₂ = 0.1127 for all data. The compound has a 2-D structure composed of NaCl-type [Bi₄Te₆] anionic layers and Cs⁺ ions residing between the layers. The [Bi₄Te₆] layers are interconnected by Bi-Bi bonds at a distance of 3.2383(10) Å. This material is a narrow gap semiconductor. Optimization studies on the thermoelectric properties with a variety of doping agents show that the electrical properties of CsBi₄Te₆ can be tuned to yield an optimized thermoelectric material which is promising for low-temperature applications. Sbl₃ doping resulted in p-type behavior and a maximum power factor of 51.5 μ W/cm·K² at 184 K and the corresponding ZT of 0.82 at 225 K. The highest power factor of 59.8 µW/cm·K² at 151 K was obtained from 0.06% Sb-doped material. We report here the synthesis, physicochemical properties, doping characteristics, charge-transport properties, and thermal conductivity. Also presented are studies on n-type CsBi₄Te₆ and comparisons to those of p-type.

Introduction

 $Bi_{2-x}Sb_{x}Te_{3-y}Se_{y}$ alloys,¹ the currently leading thermoelectric materials for room-temperature cooling applications, have been used for decades as their thermoelectric performance has reached optimal values through optimization of composition,² doping,³ and device design. There are now considerable demands in identifying new materials with more enhanced thermoelectric properties than those exhibited by currently employed materials.^{4,5} Particularly, interesting are candidate materials that could exceed the performance characteristics of $Bi_{2-x}Sb_xTe_{3-y}Se_y$ alloys at or below room temperature. To date, exploration for new materials has focused on several chemical systems such

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as ternary chalcogenides,^{6,7} skutterudites,⁸ half-heusler alloys,⁹ clathrates,¹⁰ and pentatellurides.¹¹

The challenge for superior thermoelectric materials lies in achieving simultaneously high electrical conductivity, high thermoelectric power, and low thermal conductivity. These

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properties define the thermoelectric figure of merit $ZT = (S^2\sigma/$ κ)T, where S is the thermopower, σ is the electrical conductivity, κ is the thermal conductivity, and T is the temperature. All three of these parameters are not independently controllable because they are determined by the details of the electronic structure and the charge carrier-related properties such as mobility, carrier concentration, effective mass, and scattering time. The thermal conductivity (κ) also has two contributions, one from carriers (κ_{e}) and one from lattice vibrations (κ_{l}) . The latter is in principle independently controllable through chemical manipulation.

Materials with more complex composition and structure may have complex electronic structures, which may give rise to high thermoelectric power and at the same time low thermal conductivity. The Boltzmann transport theory provides a general understanding of thermopower using the Mott formula:

$$S = \frac{\pi^2}{3} \cdot \frac{k^2 T}{e} \cdot \frac{\mathrm{d} \ln \sigma(E)}{\mathrm{d}E}|_{E=E}$$

The conductivity, $\sigma(E)$, is determined as a function of band filling or Fermi energy, and the thermopower, S, is just proportional to the logarithmic derivative of $\sigma(E)$ with respect to E near the Fermi surface. This implies that the thermopower of a material is a measure of the asymmetry in electronic structure and scattering rates near the Fermi energy, suggesting one can control simultaneously σ and S by manipulating the energy dependence of $\sigma(E)$. Another desirable way to increase ZT is to minimize κ_1 while retaining good electrical and thermopower properties.

Our approach to searching for new thermoelectrics has been to build new structures from alkali metals, bismuth and chalcogen atoms. We have reported on BaBiTe₃,¹² KBi_{6.33}S₁₀,¹³ α -, β -, γ -K₂Bi₈Q₁₃ (Q = Se, ^{6,14,15} S¹³), K_{2.5}Bi_{8.5}Se₁₄, ⁶ and KM₄- Bi_7Se_{15} (M = Sn, Pb)¹⁶ that show promising thermoelectric properties. Particularly, the compounds $K_2Bi_8Q_{13}$ (Q = Se, S) possess low symmetry and a large unit cell, with "loosely" bound K⁺ ions in channels composed of covalently bonded Bi/Q blocks. The measured properties for these compounds suggest that low thermal conductivity and promising thermoelectric properties could be achieved by introducing alkali metals in the Bi/Q (Q = Te, Se, S) binary system. To investigate isostructural tellurium compounds, we focused on the Cs/Bi/ Te system, which, however, gave an unexpected result where, instead of the Cs₂Bi₈Te₁₃ being observed, a reduced compound was isolated, CsBi₄Te₆, which can be viewed as containing Bi²⁺ ions that form novel Bi-Bi bonds.

In a preliminary communication,¹⁷ we reported that appropriate p-type doping of CsBi₄Te₆ gives rise to a high ZT_{max} of 0.8

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at 225 K. At this temperature, CsBi₄Te₆ is the best performing thermoelectric material and raises new hope for extending the use of thermoelectric materials to temperatures lower than ever before. Since then, we have identified a new dopant which allows the high ZT_{max} to be shifted to even lower temperatures in the neighborhood of 180 K. With the aid of electronic band structure calculations reported earlier,18 we present a broad and in-depth discussion of the structure property relationships in this material. We present in detail here the synthesis, physicochemical, spectroscopic, and structural characterization of CsBi₄Te₆. We also report extensive doping studies including a complete set of thermoelectric properties, electrical conductivity, Seebeck coefficient, and thermal conductivity, for both p- and n-type CsBi₄Te₆ over a wide range of temperatures.

Experimental Section

Reagents. Chemicals in this work were used as obtained: (i) bismuth, 99.999% purity, Cerac, Milwaukee, WI; (ii) tellurium powder, 99.999% purity, Cerac, Milwaukee, WI; (iii) cesium metal, 99.98% purity, Johnson and Matthey Co., Ward Hill, MA; (iv) selenium, 99.999% purity, Cerac, Milwaukee, WI; (v) antimony, 99.999% purity, Cerac, Milwaukee, WI; (vi) Bi2Te3 was prepared by melting the stoichiometric mixture of Bi and Te at 800 °C; (vii) high purity commercial reagents were used for elemental dopants (Sn, Zn, Mg, Te); (viii) the dopant compounds were prepared as described in the literature¹⁹ for SbI₃ and BiI₃, or by stoichiometric reactions of the elements at 750 °C for SnTe and In₂Te₃. These dopants were purified by sublimation before use.

Synthesis of CsBi₄Te₆. All premanipulations were carried out under a dry nitrogen atmosphere in a Vacuum Atmospheres Dri-Lab glovebox and in a Schlenk line. Cs2Te was obtained by stoichiometric reactions of elemental cesium and tellurium in liquid NH3.20 It was dried and ground to give a fine homogeneous powder prior to use. CsBi₄Te₆ could be obtained in various ways as follows:

Method A. Cs₂Te (0.192 g, 0.488 mmol) and Bi₂Te₃ (0.6 g, 0.749 mmol) were thoroughly mixed and loaded into an alumina thimble (10 mm o.d. \times 7 mm i.d. \times 75 mm), which was plugged with a graphite lid and subsequently sealed inside a silica tube (13 mm o.d. \times 11 mm i.d.) at a residual pressure of $< 10^{-4}$ Torr. The mixture was heated to 300 °C over 24 h followed by heating to 700 °C at a rate of \sim 3 °C/h. It was isothermed there for 2.5 days and then slowly cooled to 300 °C at a rate of -4 °C/h followed by cooling to 50 °C in 12 h. The product was isolated by dissolving away the residual Cs2Te with several portions of degassed dimethylformamide under a nitrogen atmosphere until the solvent remained clear. After being washed with ether and dried, shiny long silvery needles of CsBi₄Te₆ were obtained in quantitative yield.

Method B. A mixture of Cs metal (0.033 g, 0.248 mmol) and Bi₂-Te₃ (0.3 g, 0.375 mmol) was loaded in an alumina thimble. An exothermic reaction took place during mixing. The mixture was sealed by the same procedure as above and heated to 600 °C at a rate of 5 °C/h. The mixture was isothermed there for 1 day followed by slow cooling at a rate of -4 °C/h to 150 °C. The alumina thimble containing the product was immersed overnight in dried and degassed methanol under a nitrogen atmosphere. The relatively large crystals (>5 mm long) of CsBi₄Te₆ were taken out of the thimble by carefully scratching with a spatula and were washed with methanol.

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Method C. A mixture of Cs metal (0.432 g, 3.250 mmol) and Bi_2 -Te₃ (5.0 g, 6.244 mmol) was loaded and sealed as above. The mixture was heated at 250 °C for 24 h to complete the reaction of Cs metal. The resulting black material mixed with unreacted Bi_2Te_3 was slowly melted in a flame torch for a minute and then quenched in air. This method also gives a quantitative yield and is suitable for a large-scale synthesis.

Method D. Cs metal (0.1 g, 0.752 mmol) and Bi₂Te₃ (1.0 g, 1.249 mmol) were loaded separately in the two ends of a H-shaped silica tube (13 mm o.d. \times 11 mm i.d.). The other two ends were sealed under vacuum ($<10^{-4}$ Torr) while keeping the Cs-containing end in liquid N₂ temperature to avoid evaporation of the metal. The tube was heated to 250 °C over 24 h and isothermed there for 1 day followed by heating to 580 °C over 24 h. After 2 days at 580 °C, it was cooled to 50 °C in 12 h. The product obtained at 100% yield was washed with several portions of degassed methanol under nitrogen atmosphere.

The purity and homogeneity of the product obtained from each method were confirmed by comparison of the X-ray powder diffraction (XRD) pattern to that calculated from the single-crystal X-ray analysis. A quantitative analysis by energy dispersive spectroscopy (EDS) using a scanning electron microscope (SEM) was also performed on a large number of the CsBi₄Te₆ crystals and showed an average ratio of "Cs_{0.96}-Bi₄Te_{6.6}".

Doping CsBi₄Te₆. All doped materials were synthesized using doped Bi₂Te₃ as a starting material. To obtain doped Bi₂Te₃, each dopant was mixed with it and melted at 800 °C in a rocking furnace and quenched in air. In the cases of Bi and Sb doping, stoichiometrically doped Bi_{2+x}Te_{3-x} and Bi₂Sb_xTe_{3-x} (x < 0.2) were used as starting materials. The reaction of doped Bi₂Te₃ with Cs was performed by method D. After synthesis of the doped CsBi₄Te₆, crystal growth was carried out by a Bridgman technique to obtain well-oriented ingots. The ingots were then annealed at 250 °C for 2 days before measurements of charge-transport properties. A doping level in units of mol % was applied in this doping study.

Physical Measurements

Electron Microscopy. Quantitative microprobe analyses of the compound were performed with a JEOL JSM-35C scanning electron microscope (SEM) equipped with a Tracor Northern energy dispersive spectroscopy (EDS) detector. Data were acquired using an accelerating voltage of 20 kV and a 1-min accumulation time.

Differential Thermal Analysis. Differential thermal analysis (DTA) was performed with a computer-controlled Shimadzu DTA-50 thermal analyzer. The ground single crystals (\sim 20 mg total mass) were sealed in a carbon-coated silica ampule under vacuum. A silica ampule containing alumina of equal mass was sealed and placed on the reference side of the detector. The samples were heated to 800 °C at 10 °C/min, then isothermed for 2 min followed by cooling at 10 °C/min to 100 °C and finally by rapid cooling to room temperature. The reported DTA temperature is the peak temperature. The DTA sample was examined by powder X-ray diffraction after the experiment.

Raman Spectroscopy. Raman spectra were recorded on a Holoprobe Raman spectrograph. The experimental details were reported elsewhere.²¹

Infrared Spectroscopy. Optical diffuse reflectance measurements were made on the finely ground sample at room temperature. The spectrum was recorded in the infrared region $(6000-400 \text{ cm}^{-1})$ with the use of a Nicolet MAGNA-IR 750 spectrometer equipped with a collector diffuse reflectance of

Spectra-Tech, Inc. Absorption (α/S) data were calculated from the reflectance data using the Kubelka–Munk function:²² $\alpha/S = (1 - R)^2/2R$, where *R* is the reflectance at a given wavenumber, α is the absorption coefficient, and *S* is the scattering coefficient.

Charge-Transport Property Measurements. The crystals of $CsBi_4Te_6$ suitable for electrical conductivity and thermopower measurements typically exhibited lengths in the order of 1–10 mm along the needle axis that provided an excellent geometry for the measurements. DC conductivity measurements were performed in the usual four-probe geometry with 60- and 25- μ m gold wires used for the current and voltage electrodes, respectively. Conductivity data were obtained with the computer-automated system described elsewhere.^{23a} Thermoelectric power measurements were made by using a slow ac technique^{23b} with 60- μ m gold wires serving to support and conduct heat to the sample, as well as to measure the voltage across the sample resulting from the applied temperature gradient. In both measurements, the gold electrodes were held in place on the sample with a conductive gold paste.

Conductivity specimens were mounted on interchangeable sample holders, and thermopower specimens were mounted on a fixed sample holder/differential heater. Mounted samples were placed under vacuum (10^{-3} Torr) and heated to room temperature for 24 h to cure the gold contacts. For a variable-temperature run, data (conductivity or thermopower) were acquired during the warming cycle. The temperature drift rate during an experiment was kept below 1 K/min. For some samples, three to four separate variable-temperature runs were carried out to ensure reproducibility. At a given temperature, reproducibility was within $\pm 5\%$.

Hall Effect Measurements. Mobility and carrier concentration data were obtained using dc Hall effect measurements from 4.2 to 340 K using a computer-controlled five-probe technique.²³ The voltage sensing electrodes were 25 μ m diameter gold wire; the current electrodes were 60 μ m diameter gold wire and were mounted across the ends of the samples. The electrode wires were attached to the sample with gold paste. For the CsBi₄Te₆ samples, contacts made with gold paste were found to be superior in most cases to those made with silver paste. Hall measurements were performed with a 7.4 kG magnetic flux density and typically with a 1 mA applied current. All voltages were measured using a Keithley 2182 nanovoltmeter. Some Hall measurements were carried out in a reduced pressure (~ 10 mTorr) atmosphere of dry helium gas to improve thermal equilibrium. The relationship $|R_{\rm H}| = 1/ne$ was used for determining carrier concentrations, where $R_{\rm H}$ is the Hall coefficient, *n* is the carrier concentration, and *e* is the electronic charge.

Thermal Conductivity Measurements. (1) Thermal conductivity was determined using a longitudinal steady-state method over the temperature range 4-300 K. Samples were attached (using either a low melting point solder or a silverloaded epoxy) to the cold tip of the cryostat, while the other end of the sample was provided with a small strain gauge

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resistor, which serves as a heater. The temperature difference across the samples was measured using a differential chromelconstantan thermocouple. (2) Thermal conductivity measurements were also obtained using a pulse technique developed by Maldonado.²⁴ The method was modified for a computercontrolled procedure by Hogan.²⁵ The technique allows both thermal conductivity and thermopower data to be recorded during the data collection cycle. For comparison, thermoelectric power measurements were also taken in the measurement system employing the slow-ac technique described above and showed good agreement with results from the pulse technique.

Crystallography. A single crystal of CsBi₄Te₆ with dimensions 0.028 mm \times 0.051 mm \times 0.307 mm was mounted on the tip of a glass fiber. Intensity data were collected at 293 K on a Siemens SMART Platform CCD diffractometer using graphite monochromatized Mo Ka radiation over a full sphere of reciprocal space, up to 56.3° in 2θ . The individual frames were measured with an ω rotation of 0.3° and an acquisition time of 45 s. The SMART²⁶ software was used for the data acquisition, and SAINT²⁷ was used for data extraction and reduction. The absorption correction was done using SADABS.

Structure solution and refinement for the compound were done with the SHELXTL²⁸ package of crystallographic programs. Systematic absence conditions of the collected data suggested either the C2/m, C2, or Cm space group. Direct methods succeeded with the lower symmetry space group Cm (No. 8) and gave a reasonable structural model. This model possessed a center of inversion, and it was confirmed with the MISSYM algorithm²⁹ as implemented in the PLATON program,³⁰ suggesting the correct space group C2/m. Structure refinement in C2/m gave 4.34/10.17% of the final R_1/wR_2 .

The complete data collection parameters and details of the structure solution and refinement for CsBi₄Te₆ are given in Table 1. The fractional coordinates and temperature factors (U_{eq}) of all atoms with estimated standard deviations are given in Table 2.

Results and Discussion

Synthesis and Physicochemical Properties. The challenge in exploring new alkali metal bismuth telluride compounds is the exceptional thermodynamic stability of Bi2Te3. Our investigation over a wide range of reaction conditions of the Cs/Bi/ Te suggests that CsBi₄Te₆ is the only ternary compound in this system. Although a compound with a composition of CsBiTe₂ has been proposed,³¹ it was not found at all in our investigations of the Cs/Bi/Te system. CsBi₄Te₆ could be prepared in a reaction of Cs₂Te and Bi₂Te₃ with a ratio of 0.65/1 at 650 °C for 1 day. Under such a condition, the highly reactive Cs₂Te breaks down Bi₂Te₃. This reaction is remarkable because the formation of CsBi₄Te₆ requires the formal reduction of Bi³⁺ to Bi²⁺ and concomitant oxidation of Te²⁻. This is a rare and difficult redox

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Table 1. Summary of Crystallographic Data and Structural Analysis for CsBi₄Te₆

formula	CsBi ₄ Te ₆
formula weight	1734.43
crystal habit	silvery white needle
crystal size, mm ³	$0.028 \times 0.051 \times 0.307$
space group	<i>C</i> 2/ <i>m</i> (No. 12)
a, Å	51.9205(8)
b, Å	4.40250(10)
<i>c</i> , Å	14.5118(3)
β , deg	101.4800(10)
$Z; V, Å^3$	8; 3250.75(11)
$D_{\rm calc},{\rm gcm}^{-3}$	7.088
temp, K	293(2)
λ (Mo K α), Å	0.71069
absorption coeff, mm ⁻¹	55.899
F(000)	5592
$\theta_{\min} - \theta_{\max}$, deg	1.43-28.17
index ranges	$-68 \le h \le 68, -5 \le k \le 5,$
	$-19 \le l \le 18$
total reflns collected	18 450
independent reflns	4373 [R(int) = 0.0767]
refinement method	full-matrix least-squares on F^2
data/restraints/params	4373/0/134
final <i>R</i> indices $[I > 2\sigma(I)]^{a,b}$	$R_1 = 0.0434$, wR2 = 0.1017
<i>R</i> indices (all data) ^{a,b}	$R_1 = 0.0585$, wR2 = 0.1127
extinction coeff	0.000076(6)
largest diff. peak and hole, $e \cdot A^{-3}$	4.344 and -2.490
GOF on F^2	1.050

 ${}^{a}R_{1} = \sum ||F_{o}| - |F_{c}|| / \sum ||F_{o}||. {}^{b} wR_{2} = \{\sum [w(F_{o}^{2} - F_{c}^{2})^{2}] / \sum [w(F_{o}^{2})^{2}] \}^{1/2}.$

Table 2. Fractional Atomic Coordinates (×10⁴) and Equivalent Atomic Displacement Parameter ($A^2 \times 10^3$) for CsBi₄Te₆ with Estimated Standard Deviations in Parentheses

	Х	у	Ζ	U(eq) ^a
Bi(1)	1362(1)	0	7502(1)	17(1)
Bi(2)	2124(1)	5000	-888(1)	18(1)
Bi(3)	1628(1)	0	921(1)	18(1)
Bi(4)	886(1)	5000	-627(1)	18(1
Bi(5)	2353(1)	5000	-7410(1)	17(1
Bi(6)	1146(1)	5000	2782(1)	17(1)
Bi(7)	150(1)	0	7878(1)	18(1)
Bi(8)	396(1)	0	1365(1)	18(1)
Cs(1)	543(1)	0	5090(1)	26(1)
Cs(2)	3130(1)	0	-5163(1)	28(1)
Te(1)	1533(1)	5000	-722(1)	14(1)
Te(2)	800(1)	0	7845(1)	16(1)
Te(3)	1226(1)	5000	6089(1)	18(1)
Te(4)	2020(1)	0	7561(1)	16(1)
Te(5)	2250(1)	0	766(1)	14(1)
Te(6)	1043(1)	0	1003(1)	15(1)
Te(7)	1757(1)	5000	-7570(1)	16(1)
Te(8)	1236(1)	0	4213(1)	18(1)
Te(9)	2396(1)	0	-5982(1)	18(1)
Te(10)	575(1)	5000	2811(1)	18(1)
Te(11)	-76(1)	5000	3592(1)	19(1)
Te(12)	322(1)	5000	-383(1)	17(1)

^{*a*} U(eq) is defined as one-third of the trace of the orthogonalized U_{ij} tensor.

reaction and unprecedented in A_2Q/Bi_2Q_3 (A = alkali metal; Q = chalcogen) reaction systems.^{6,12-16} It is the first example in which Bi³⁺ is reduced in a bismuth chalcogenide compound forming a Bi-Bi bond (see below). That it happens at all attests to the high thermodynamic stability of CsBi₄Te₆. Interestingly, $CsBi_4Te_6$ is also unique in that it has neither alkali analogues (e.g., K, Rb) nor Sb or Se analogues. A small amount of Sb and Se can be added in the structure to form $CsBi_{4-x}Sb_{x}Te_{6}$ (0) < x < 0.8) and CsBi₄Te_{6-y}Se_y (0 < y < 1.2), but complete substitution was found to be impossible.

Given that CsBi₄Te₆ is a reduced form of Bi₂Te₃, we also devised rational synthetic routes involving the direct combina-

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⁽²⁵⁾ Hogan, T. P. Ph.D. Dissertation, Northwestern University, 1996.



Figure 1. Perspective view of the structures of (a) $CsBi_4Te_6$ along the *b*-axis. Bi atoms are blue; Te atoms are yellow. (b) $CsPbBi_3Te_6$ composed of NaCl-type layers. The red atoms are Bi or Pb atoms (mixed occupancy). In $CsBi_4Te_6$, the $[Bi_4Te_6]$ slabs have a finite width, with 12×23 Å² cross-section area, are interconnected side by side, and are linked by Bi–Bi bonds at 3.238(1) Å. In $CsPbBi_3Te_6$, the slabs have infinite width and extend continuously along the crystallographic *a*-axis.

tion of Cs metal with Bi_2Te_3 . For example, melting the mixture of Cs metal³² and Bi_2Te_3 with a torch flame produces quantitatively a pure polycrystalline ingot of $CsBi_4Te_6$ in a very short period. Alternatively, the slow vapor transport of Cs metal to Bi_2Te_3 is also successful and forms well-oriented $CsBi_4Te_6$ ingots with good reproducibility. The compound $CsBi_4Te_6$ has a characteristic needlelike morphology and good stability in air and water.

DTA performed on $CsBi_4Te_6$ showed that the compound melts at 545 °C.³³ Molten $CsBi_4Te_6$ can be susceptible to evaporative Cs loss, giving rise to some Bi_2Te_3 . Therefore, a successful recrystallization from the melt must take into account the vapor pressure. The Raman spectrum of $CsBi_4Te_6$ crystals shows three Bi–Te vibration modes at 111, 133, and 181 cm⁻¹ that are also consistently observed in Bi_2Te_3 .

Structure Description. $CsBi_4Te_6$ crystallizes in the space group C2/m and presents a new type of layered structure composed of anionic infinitely long $[Bi_4Te_6]^-$ blocks and Cs^+

ions residing in the interlayer space, see Figure 1a. The $[Bi_4Te_6]^-$ block can be regarded as an excised fragment out of the NaCl lattice. This block is two Bi octahedra thick and four Bi octahedra wide $(12 \times 23 \text{ Å}^2)$ in the *ac*-plane and infinitely long in the *b*-direction, thus having the shape of an infinite rod that has a rectangular cross section. We emphasize, therefore, that these slabs are strongly anisotropic to the point that the structure is in essence one-dimensional, and this is consistent with the characteristic needlelike morphology of the crystals, see Figure 2. The cleavage of these crystals is strongly preferred along the *ab*-plane which is the plane accommodating the Cs layers.

Bi₂Te₃- and NaCl-type Bi/Q (Q = Te, Se, S) structural units are the archetypical building blocks of group 15 metal chalcogenides.^{4b} These blocks are combined in a variety of different fashions and different sizes to build unique structures, as in α-, β-K₂Bi₈Q₁₃ (Q = S,¹³ Se^{6,14}), K_{2.5}Bi_{8.5}Se₁₄,⁶ KBi_{6.33}S₁₀,¹³ and KM₄Bi₇Se₁₅ (M = Sn, Pb).¹⁶ In CsBi₄Te₆, however, the Bi/Te layers consist of only NaCl-type Bi/Te blocks in which inner Bi atoms are coordinated to six Te atoms in a slightly distorted octahedral geometry with distances ranging from 2.974(1) to 3.403(1) Å, see Tables 3 and 4. Interestingly, this preference of structure type for the Bi/Te building block is also

⁽³²⁾ Because of difficulty in handling the exact amount of Cs metal, a slight excess (≤3%) of Cs metal was used in all reactions.

⁽³³⁾ A loss of Cs metal may take place in differential thermal analysis due to the reaction of CsBi₄Te₆ with a silica container. With the use of a normal furnace and a graphite container in which any side reaction can be avoided, however, congruent melting of CsBi₄Te₆ was confirmed by XRD after a melting/recrystallization cycle.



Figure 2. The crystals (top) and oriented ingot (bottom) of $CsBi_4Te_6$. The direction of crystal growth is the *b*-axis in the structure.

Table 3.	Selected	Bond	Distances	(Å) in	CsBi ₄ Te ₆	with	Standard
Deviation	s in Parer	nthese	s	. ,			

$Bi(1)-Te(1) \times 2$	3.3713(11)	Bi(6)-Te(7)	3.3092(14)
Bi(1)-Te(2)	3.0538(14)	Bi(6)-Te(7)	3.3087(14)
Bi(1)-Te(3)	2.9956(10)	$Bi(6)$ -Te(8) $\times 2$	2.9981(11)
Bi(1)-Te(3)	2.9957(10)	Bi(6)-Te(10)	2.9740(14)
Bi(1)-Te(4)	3.4031(14)	Bi(7)-Te(2)	3.3835(14)
Bi(2)-Te(1)	3.1229(14)	$Bi(7)$ -Te(11) $\times 2$	3.0362(11)
Bi(2)-Te(4) × 2	3.1180(11)	$Bi(7)-Te(12) \times 2$	3.3334(12)
Bi(2)-Te(5)	3.2205(14)	Bi(7)-Bi(8)	3.2383(10)
$Bi(2)$ -Te(5) $\times 2$	3.2263(11)	$Bi(8)$ -Te(10) \times 2	3.0558(11)
$Bi(3)$ -Te(1) $\times 2$	3.2099(11)	$Bi(8)$ -Te(12) \times 2	3.3231(12)
Bi(3)-Te(5)	3.2798(13)	Cs(1)-Te(2)	3.956(2)
Bi(3)-Te(6)	3.0640(14)	Cs(1)-Te(3) × 2	4.182(2)
Bi(3)-Te(7) × 2	3.0830(11)	Cs(1)-Te(8)	4.047(2)
Bi(4)-Te(1)	3.3920(14)	Cs(1)-Te(10) × 2	4.003(2)
Bi(4)-Te(2) × 2	3.0925(11)	$Cs(1)$ - $Te(11) \times 2$	4.137(2)
$Bi(4)$ -Te(6) $\times 2$	3.2161(11)	$Cs(1)$ - $Te(11) \times 2$	4.029(2)
Bi(4)-Te(12)	3.0178(14)	Cs(2)-Te(3)	3.842(2)
Bi(5)-Te(4)	3.3033(14)	Cs(2)-Te(4) × 2	4.060(2)
Bi(5)-Te(4)	3.3027(14)	Cs(2)-Bi(6)	4.570(2)
$Bi(5)$ -Te(5) $\times 2$	3.4024(11)	Cs(2)-Te(7)	3.892(2)
Bi(5)-Te(7)	3.0604(14)	Cs(2)-Te(8) × 2	3.973(2)
$Bi(5)$ -Te(9) \times 2	3.0012(11)	Cs(2)-Te(9)	3.761(2)
Bi(6)-Te(6) × 2	3.3538(11)	Cs(2)-Te(9) × 2	4.104(2)

shown in other bismuth telluride compounds containing Rb and Cs. For example, $Rb_{0.5}Bi_{1.83}Te_3$,³⁴ AMBi₃Te₆, and AM₂Bi₃Te₇ (A = Rb, Cs; M = Sn, Pb)³⁴ consist of similar NaCl-type Bi/

Table 4.	Selected Bond Angles	(deg) i	in CsBi ₄ Te ₆	with	Standard
Deviation	s in Parentheses				

Te(1) - Bi(1) - Te(1)	81.53(3)	Te(12)-Bi(4)-Te(1)	175.66(4)
Te(1)-Bi(1)-Te(4)	82.51(3)	Te(4)-Bi(5)-Te(5)	87.32(3)
Te(2)-Bi(1)-Te(1)	89.48(3)	Te(5)-Bi(5)-Te(5)	80.63(3)
Te(3)-Bi(1)-Te(1)	91.94(2)	Te(7)-Bi(5)-Te(5)	86.57(3)
Te(3)-Bi(1)-Te(2)	90.59(3)	Te(9)-Bi(5)-Te(4)	96.24(3)
Te(3)-Bi(1)-Te(3)	94.58(4)	Te(9)-Bi(5)-Te(5)	92.36(2)
Te(3)-Bi(1)-Te(4)	96.58(3)	Te(9)-Bi(5)-Te(7)	89.19(3)
Te(3)-Bi(1)-Te(1)	173.47(3)	Te(9)-Bi(5)-Te(9)	94.35(4)
Te(2)-Bi(1)-Te(4)	169.41(4)	Te(7)-Bi(5)-Te(4)	171.99(4)
Te(1) - Bi(2) - Te(5)	89.99(3)	Te(9)-Bi(5)-Te(5)	172.01(3)
Te(4)-Bi(2)-Te(1)	91.41(3)	Te(6)-Bi(6)-Te(6)	82.04(3)
Te(4)-Bi(2)-Te(4)	89.82(4)	Te(7)-Bi(6)-Te(6)	83.80(3)
Te(4)-Bi(2)-Te(5)	93.83(3)	Te(8)-Bi(6)-Te(6)	91.73(2)
Te(4)-Bi(2)-Te(5)	92.05(2)	Te(8)-Bi(6)-Te(7)	94.93(3)
Te(5)-Bi(2)-Te(5)	86.05(4)	Te(8)-Bi(6)-Te(8)	94.48(4)
Te(5)-Bi(2)-Te(5)	84.61(3)	Te(10)-Bi(6)-Te(6)	90.22(3)
Te(1)-Bi(2)-Te(5)	172.60(4)	Te(10)-Bi(6)-Te(8)	90.45(3)
Te(4)-Bi(2)-Te(5)	177.64(3)	Te(8)-Bi(6)-Te(6)	173.74(3)
Te(1)-Bi(3)-Te(1)	86.59(4)	Te(10)-Bi(6)-Te(7)	172.07(5)
Te(1)-Bi(3)-Te(5)	87.55(3)	Bi(8)-Bi(7)-Te(12)	82.14(3)
Te(6)-Bi(3)-Te(1)	91.25(3)	Te(11) - Bi(7) - Te(2)	88.74(3)
Te(6)-Bi(3)-Te(7)	92.75(3)	Te(11) - Bi(7) - Bi(8)	103.93(3)
Te(7)-Bi(3)-Te(1)	91.00(2)	Te(11) - Bi(7) - Te(11)	92.94(4)
Te(7)-Bi(3)-Te(5)	88.40(3)	Te(11) - Bi(7) - Te(12)	91.76(2)
Te(7) - Bi(3) - Te(7)	91.12(4)	Te(12)-Bi(7)-Te(2)	83.90(3)
Te(6) - Bi(3) - Te(5)	178.35(4)	Te(12)-Bi(7)-Te(12)	82.65(4)
Te(7)-Bi(3)-Te(1)	175.37(4)	Bi(8)-Bi(7)-Te(2)	161.37(4)
Te(2)-Bi(4)-Te(1)	88.47(3)	Te(11) - Bi(7) - Te(12)	171.18(4)
Te(2)-Bi(4)-Te(2)	90.77(4)	Bi(7)-Bi(8)-Te(12)	106.45(3)
Te(2)-Bi(4)-Te(6)	91.11(2)	Te(10)-Bi(8)-Bi(7)	86.27(3)
Te(6)-Bi(4)-Te(1)	85.46(3)	Te(10)-Bi(8)-Te(10)	92.17(4)
Te(6)-Bi(4)-Te(6)	86.38(4)	Te(10)-Bi(8)-Te(12)	91.16(2)
Te(12) - Bi(4) - Te(2)	94.57(3)	Te(12)-Bi(8)-Te(12)	82.97(4)
Te(12) - Bi(4) - Te(6)	91.39(3)	Te(10)-Bi(8)-Te(12)	167.05(4)
Te(2)-Bi(4)-Te(6)	173.60(4)		

Te layers but of infinite width, see Figure 1b. This is probably due to the size effect of alkali metal versus Bi/Q block; that is, large alkali cations, Rb and Cs, fit better in NaCl-type blocks than in Bi_2Te_3 -type blocks, providing a smaller interlayer space for alkali metals.³⁵

CsBi₄Te₆ can be regarded as a reduced version of Bi₂Te₃. Apparently, the addition of one electron per 2 equiv of Bi₂Te₃ does not give a formal intercalation compound (e.g., Cs_xBi₂Te₃), but causes a rather dramatic reorganization of the Bi₂Te₃ framework and reveals an inability to delocalize such electrons. The added electrons then localize on Bi atoms, giving formally Bi²⁺ (rare in Bi chemistry) and Bi–Bi bonds of 3.2383(10) Å. These unusual bonds "stitch" the [Bi₄Te₆] slabs together. The Bi–Bi distance in CsBi₄Te₆ is comparable to a Bi–Bi distance of 3.267(6) Å in BiTe,³⁶ a metallic compound possessing a layer of Bi atoms inserted between Bi₂Te₃ layers. Interestingly, isolated Bi–Bi bonds in solids are a rare occurrence. The other example of such a functionality we are aware of is in Bi₂Ga₂Q₈ (Q = S, Se), where the relevant distance is 3.148 Å.³⁷

The anionic $[Bi_4Te_6]$ slabs in CsBi₄Te₆ are separated by layers of Cs⁺ cations, which are in two different coordination environments. The Cs(1) ions are located at the corner of each $[Bi_4Te_6]$ slab and coordinated by 10 peripherally distributed Te

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⁽³⁵⁾ This behavior is also found in selenide compounds, A₂Bi₈Se₁₃ (A = Rb, Cs), which contain only NaCl-type Bi/Se blocks connected by short CdI₂-type fragments: Iordanidis, L.; Brazis, P. W.; Kyratsi, T.; Ireland, J.; Lane, M.; Kannewurf, C. R.; Chen, W.; Dyck, J. S.; Uher, C.; Ghelani, N. A.; Hogan, T.; Kanatzidis, M. G. *Chem. Mater.* **2001**, *13*, *622*.

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Figure 3. Typical electrical conductivity and thermopower for a singlecrystal sample of as-prepared $CsBi_4Te_6$ as a function of temperature. The measurements were carried out along the needle direction.

atoms. The Cs(2) ions are located between the $[Bi_4Te_6]$ slabs and coordinated by nine terminal Te atoms. The average Cs– Te distance is 4.025 Å. The thermal displacement parameters of Cs atoms are about 1.6 times greater than those of Bi and Te atoms, suggesting that Cs atoms may be playing the role of rattlers. If Cs atoms are dynamically rattling in the cages, they will help to reduce the lattice thermal conductivity of CsBi₄Te₆ by scattering heat-carrying acoustic phonons.³⁸ However, the possibility of static disorder of Cs atoms, which are also represented by relatively high thermal displacement parameters, cannot be excluded in this case.

Electronic, Charge-Transport, and Thermoelectric Properties. Undoped "As-Prepared" CsBi₄Te₆. Before we describe the dependence of electronic and thermoelectric properties of $C_{s}Bi_{4}Te_{6}$ as a function for doping, we need to characterize the properties of the so-called "as-prepared" material, which is material obtained from a preparative reaction without any intentional attempt to dope it. Of course, there is no such entity as undoped (i.e., intrinsic semiconductor) material, as it is impossible to prepare samples free of impurities. Several crystals of each sample batch were examined to check how reproducible the transport properties were among the crystals of different batches. There is a large variation in the properties of the "asprepared" crystals representing different degrees of doping due to adventitious impurities. The room-temperature conductivity and thermopower for single crystals of "as-prepared" CsBi₄Te₆ are in the range of 900-450 S/cm and 90-150 μ V/K, respectively, see Figure 3. These samples were invariably p-type, indicating holes as the majority carrier. The conductivity and thermopower data of CsBi₄Te₆ follow typical behavior of a degenerate narrow gap semiconductor. The conductivity exhibits a weak negative temperature dependence, and the thermopower exhibits a positive temperature dependence and large values. By comparison, at room temperature the unoptimized Bi₂Te₃ has similar properties with 450–1500 S/cm and 80–150 μ V/ K, whereas optimized $Bi_{2-x}Sb_xTe_{3-y}Se_y$ samples, exhibiting ZT \approx 1 and used in thermoelectric devices, show \sim 800–1000 S/cm and $\sim \pm 220 \,\mu \text{V/K}$. The rather similar magnitudes of

conductivity and thermopower of $CsBi_4Te_6$ as compared to those of Bi_2Te_3 and the ability to dramatically optimize the thermo-

electric properties of Bi₂Te₃ via doping encouraged us to pursue systematic exploratory doping studies on CsBi₄Te₆ as presented below.

Optimization through Doping: p-type CsBi₄Te₆. In general, the charge-transport properties of narrow gap semiconductors are sensitive to extremely small changes in effective mass, mobility, and concentration of carriers around the Fermi level. To probe the ability of $CsBi_4Te_6$ to change its electrical properties by changing these parameters, we added various extrinsic dopants into the reaction mixture in anticipation that they will end up in the structure and will either donate holes or electrons to the system. Our aim was to learn how this new material is doped by various chemical agents and to be able to create and control p-type and n-type samples with the ultimate goal of maximizing the thermoelectric figure of merit ZT. This optimization process is necessary to achieve suitability for a practical thermoelectric device.

The doping of CsBi₄Te₆ was done with various chemical "impurities" such as SbI₃, BiI₃, CuCl, SnTe, In₂Te₃, Sb, Bi, Sn, Zn, Mg, Te, Ge, Pt, and Pr in amounts ranging from 0.02 to 4.0 mol %. The rationale behind the choice of these particular agents varied. In most cases, we chose the dopants to achieve a change in carrier concentration or the type of majority carrier (e.g., substitution of Sb for Te or Te for Bi is expected to create a hole or an electron carrier, respectively). In several other cases, the dopants were chosen almost randomly and in an exploratory fashion (e.g., Mg, Pt, Zn) to probe how they acted when introduced in the structure. The doping studies showed clearly that the charge-transport properties of CsBi₄Te₆ greatly rely on both the type and the percent of the doping agent. To evaluate the effectiveness of each dopant, the power factor $(S^2\sigma)$ of the doped material was calculated from the conductivity and thermopower data as a function of temperature. These power factor data are also necessary to determine the temperature (at the maximum $S^2\sigma$) of the highest thermoelectric efficiency as well as the optimal doping level for each dopant, see Table 5.

SnTe was examined to substitute Bi atoms with Sn atoms and generate more carriers. This was expected to increase the conductivity and decrease the thermopower with increasing SnTe. Indeed, from an average value of 363 S/cm for the undoped material at room temperature, SnTe doping in the range of 0.3-1.5% gradually increased the conductivity from 899 to 2584 S/cm and decreased the thermopower from 103 to $54 \,\mu$ V/K (room-temperature values).

SbI₃ and BiI₃ were chosen with the purpose of placing iodine atoms on the Te sites. Surprisingly, the materials were consistently p-doped rather than n-doped over the range of doping level we applied. The most promising material was 0.05 mol % SbI₃-doped CsBi₄Te₆, having a maximum power factor of \sim 51.5 μ W/cm·K² at 184 K where the values of conductivity and thermopower reach \sim 1927 S/cm and \sim 163 μ V/K respectively, see Table 5 and Figure 4. Power factors for each doped CsBi₄Te₆ sample giving noticeably high values are shown as a function of temperature in Figure 5. It is also interesting to compare the maximum power factor of the doped CsBi₄Te₆ to that of a commercial p-type $Bi_{2-x}Sb_xTe_3$ alloy. The maximum value for a p-type $Bi_{2-x}Sb_xTe_3$ sample is ~42.5 μ W/cm·K² at \sim 225 K, which is below the corresponding values for all 0.05% SbI₃-doped samples examined. It is significant to point out that the maximum in power factor occurs at \sim 184 K, which is 70-

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Table 5. Power Factor Values for Each Dopant at Room Temperature and the Temperature Where the Maximum Value Occurs, and Electrical Conductivity and Thermopower Values Giving Rise to the Maximum Power Factor

				σ^a	S ^a	temp ^a
	concentration	<i>S</i> ² <i>σ</i> (295 K)	max $S^2\sigma$	(max $S^2\sigma$)	(max $S^2\sigma$)	(max $S^2\sigma$)
dopant	mol %	μ W/cm•K ²	μ W/cm•K ²	S/cm	μ V/K	К
p-Bi ₂ Te ₃ ^b		39.9	42.5			225
undoped		4.8	6.4			211
SbI ₃	0.02	26.7	28.8	1283	150	235
	0.05	34.0	51.5	1927	163	184
	0.1	11.0	22.1	1197	136	165
	0.2	9.0	13.9	1107	112	214
	0.3	5.0	7.1	569	112	166
	0.4	6.3	7.2	864	91	248
BiI ₃	0.1	7.6	8.8	852	102	235
	0.2	11.2	11.5	1193	98	270
	0.3	14.5	45.0	4870	96	147
	0.4	3.0	3.0	960	55	295
CuCl	0.02	8.0	8.9	883	101	250
	0.05	11.1	15.1	1579	98	181
	0.1	6.6	6.7	845	89	274
	0.5	7.3	8.1	904	94	225
SnTe	0.3	9.5	11.9	1313	95	229
	0.6	7.8	7.9	1379	76	272
	1.0	4.9	5.1	1734	65	258
	1.5	3.4	3.5	3176	50	282
Sn	0.2	1.3	1.3	836	39	295
	0.5	0.4	21.9	5499	-63	127
	1.0	0.02	7.4	1292	-76	139
	2.0	0.08	4.6	3130	-39	131
In ₂ Te ₃	0.3	1.6	1.6	655	49	295
	0.6	3.2	3.2	839	62	295
	0.9	13.8	17.0	1821	97	214
	1.5	16.2	30.6	2778	104	159
	3.0	0.03	9.6	1175	-90	136
	4.0	1.7	3.4	1558	-47	111
Bi	0.02	6.8	6.9	820	92	290
	0.06	6.0	9.4	731	114	212
	0.1	15.7	40.9	1170	187	171
	0.2	10.5	32.3	1607	142	217
	0.3	4.4	4.9	815	77	253
Sb	0.02	8.1	16.9	1846	96	161
	0.06	16.0	59.8	4562	115	151
	0.1	13.5	39.0	3846	101	109
	0.2	16.8	20.4	1093	136	224
	0.3	29.6	56.2	4550	111	190
Zn	0.3	0.03	16.7	3335	-71	156
	0.5	21.3	23.2	978	154	266
	1.0	5.0	6.2	1987	56	242
Mg	0.1	1.8	1.8	1463	35	295
	0.3	2.1	8.0	2348	-58	107
Те	1.0	0.5	23.8	2709	-94	123

^{*a*} p-type Bi₂Te₃ samples and data obtained from Marlow Industries, Inc., Dallas, Texas. ^{*b*} Schindler, J. L.; Hogan, T. P.; Brazis, P. W.; Kannewurf, C. R.; Chung, D.-Y.; Kanatzidis, M. G. *Mater. Res. Soc. Symp. Proc.* **1997**, 478, 327–332.

100 K lower than that of the best $Bi_{2-x}Sb_xTe_3$ alloys. The latter show maxima in the range 250–300 K depending on doping. Therefore, it is clear that the CsBi₄Te₆ system surpasses the performance of $Bi_{2-x}Sb_xTe_3$ alloys when the temperature falls below ~250 K, establishing the cesium compound as a new low-temperature thermoelectric p-type material. Clearly, this is encouraging and opens possibilities for the realization of new low-temperature thermoelectric devices.

The temperature of the power factor maximum in $CsBi_4Te_6$ can be shifted up or down depending on the nature of the dopant. Of particular interest is the ability to push the temperature maximum even lower. In this respect, the use of BiI_3 as dopant gives even more exciting results than SbI_3 . We observed that 0.3% BiI_3 doping resulted in a power factor maximum of ~45.0



Figure 4. Variable-temperature electrical conductivity and thermopower for a single crystal of 0.05% SbI₃-doped CsBi₄Te₆.



Figure 5. Power factors as a function of temperature for a $CsBi_4Te_6$ sample doped with (a) 0.05% SbI₃, (b) 0.1% Bi, (c) 0.3% Sb, (d) 0.06% Sb, and (e) 0.3% BiI₃. For comparison, the power factor data of (g) an "as-prepared" $CsBi_4Te_6$ sample and (h) commercial p-type doped $Bi_{2-x}Sb_xTe_3$ are shown.

 μ W/cm·K² at ~147 K, see Figure 5e. This is a record low temperature for a p-type thermoelectric compound, suggesting that a variety of cooling applications may be possible in a relatively wide range of temperatures with CsBi₄Te₆.

The results from SbI3 and BiI3 doping are not consistent with iodine atoms occupying Te sites but instead are in agreement with what would be expected if Sb or Bi atoms were replacing Te atoms. The Sb and Bi atoms having only five valence electrons would introduce a hole in the valence Te-based band in which each Te atom brings six electrons. The fate of I⁻ is not clear. We surmise that it may not even be incorporated in the compound having phase separated as trace CsI. Based on this assumption, iodine is not necessary and elemental dopants of Sb and Bi should and do reproduce the high power factors. The obtained power factors from Sb and Bi doping are about $40-60 \,\mu\text{W/cm}\cdot\text{K}^2$, similar to those obtained for the best SbI₃and BiI₃-doped materials. 0.1% Bi-doped CsBi₄Te₆ shows a significant improvement in thermopower, of which the maximum is 198 μ V/K at 224 K. This is the highest value CsBi₄Te₆ has ever shown, and the maximum power factor of 40.9 μ W/ cm·K² occurs at 171 K, Figures 5b and 6a. Like 0.05% SbI₃doped CsBi₄Te₆, 0.06% Sb doping also shows a very high power factor which reaches the highest value, 59.8 μ W/cm·K², at 151 K, Figures 5d and 6b. These high power factors are attributed to high thermopower in Bi doping and to high conductivity in Sb doping. The temperatures at maximum power factor in these two cases are also lower than 184 K for 0.05% SbI3-doped CsBi₄Te₆.



Figure 6. Variable-temperature electrical conductivity and thermopower for single crystals of (a) 0.1% Bi-doped and (b) 0.06% Sb-doped CsBi₄-Te₆.



Figure 7. Variable-temperature thermopower data for single crystals of "as-prepared" and doped $CsBi_4Te_6$: (a) "as-prepared", (b) 0.3% SnTe, (c) 0.6% SnTe, (d) 1.0% SnTe, (e) 1.5% SnTe, (f) 0.2% Sn, (g) 0.5% Sn, (h) 1.0% Sn, and (i) 2.0% Sn.

n-type $CsBi_4Te_6$. Following the optimization of p-type samples of $CsBi_4Te_6$, we became interested in n-type materials and their ability to be optimized to a high ZT. Given that iodide doping in the form of SbI_3 and BiI_3 did not give the n-type sample, we carried out a broad search for dopants. We found that Sn, Mg, Zn, Ge, Pr, In_2Te_3 , and excess Te result in n-type conductivity. We believe that in the case of In_2Te_3 and Te the n-type behavior originates from Te atom substitution on Bi sites in the structure. It is not clear why the elemental dopants Sn, Mg, Zn, Ge, and Pr gave n-type samples.

Sn doping above the 0.5% level turned the type of charge transport to n-type, see Figure 7. This is consistent with the results presented above that increasing SnTe doping decreased the thermopower, annihilating the p-type carriers. The n-type



Figure 8. Variable-temperature electrical conductivity and thermopower for a single crystal of (a) 3.0% In₂Te₃-doped and (b) 1.0% Te-doped CsBi₄-Te₆.

behavior appears, that beyond a certain concentration level of Sn the number of electrons exceeds that of holes. One mechanism for generating electron carriers is through Sn atom substitution of Bi atom in the structure. Sn doping does not show a clear systematic dependence upon the doping level as observed in SnTe doping. The room-temperature conductivity is in the range from 560 S/cm for 1.0% Sn doping to 1655 S/cm for 0.5% Sn doping.

Doping with In₂Te₃ has been known to produce a weak donor effect in Bi₂Te₃.³⁹ Likewise, CsBi₄Te₆ doped with In₂Te₃ exhibits n-type behavior at high concentration of In₂Te₃, see Figure 8a. The maximum negative thermopower of $-95 \mu V/K$ was observed at 160 K from a 3.0% doped sample, see Figure 9A.

When $CsBi_4Te_6$ was synthesized with a slight excess of Te, n-type material was obtained probably because excess Te atoms occupy Bi sites. The maximum thermopower value of -95 μ V/K was observed at 160 K in 1.0% Te-doped material, see Figure 8b.

The elemental dopants, Zn and Mg, provided n-type conductivity perhaps due to their small size that allows them to be placed in interstitial spaces of the structure releasing two electrons per atom. The type and concentration of the majority carrier significantly depend on the doping level of Zn and Mg, see Figure 9B.

Another interesting way to produce n-type material is to anneal p-type $CsBi_4Te_6$ at 250 °C. For example, an annealed sample of p-type $CsBi_4Te_6$ at 250 °C for over 2 h under vacuum

⁽³⁹⁾ Chizhevskaya, S. N.; Shelimova, L. E. Inorg. Mater. 1995, 31, 1083– 1095.



Figure 9. Variable-temperature thermopower data for single crystals of (a) "as-prepared" CsBi₄Te₆ and (A) In₂Te₃-doped with (b) 0.15%, (c) 0.3%, (d) 0.6%, (e) 0.9%, (f) 1.5%, (g) 2.0%, (h) 3.0%, and (i) 4.0% and (B) doped with (b) 0.3% Zn, (c) 0.5% Zn, (d) 1.0% Zn, (e) 0.1% Mg, and (f) 0.3% Mg.

turned out to be an n-type material with a maximum thermopower of $-93 \ \mu\text{V/K}$ at 220 K ($-74 \ \mu\text{V/K}$ at room temperature). The reason for this p- to n-type conversion is probably due to the fact that a loss of Te atoms in Bi/Te layers under vacuum at an elevated temperature could provide additional electrons.⁴⁰

It is very encouraging that CsBi₄Te₆ is subject to considerable doping manipulation, much like Bi₂Te₃, and to production of both p- and n-type materials which are necessary to build thermoelectric devices. For the p-type materials, which CsBi₄-Te₆ tends most likely to be (see the Electronic Band Structure section), maximum power factors of 51.5, 59.8, 45.0, and 40.9 μ W/cm·K² were measured at 184, 151, 147, and 171 K, respectively, by 0.05% SbI₃, 0.06% Sb, 0.3% BiI₃, and 0.1% Bi doping. From these results, Bi and Sb appear to be very effective p-type dopants. In contrast, n-type doping on CsBi₄- Te_6 was achieved with only a few doping agents in relatively high doping concentrations, see Table 5. The highest power factors were obtained by 0.5% Sn and 1.0% Te doping with 21.9 and 23.8 μ W/cm·K² at the temperatures of 127 and 123 K, respectively, see Figure 10. Therefore, sophisticated chemical manipulations are needed to further improve the power factor not only for n-type CsBi₄Te₆ but also for p-type. Although doping CsBi₄Te₆ with the above reagents apparently occurs, it is not clear yet which sites in the crystal structure are being affected by each dopant.



Figure 10. Power factors as a function of temperature for an n-type C_8Bi_4 -Te₆ sample doped with (a) 3.0% In₂Te₃, (b) 1.0% Te, and (c) 0.5% Sn.

Figure 11 presents ZT versus temperature of a number of high-performing TE materials; as shown, several exceed ZT = 1 at high temperatures (>600 K). However, below room temperature, except for $Bi_{2-x}Sb_xTe_{3-y}Se_y$, almost no materials with high ZT have been reported. In this figure, it should be noted that the superlattice $Bi_2Te_3/Sb_2Te_3^{41}$ showing ZT $\approx 1.7-2.6$ is a thin film material synthesized by a considerably different technique from that for the bulk materials such as CsBi₄Te₆, and it may only be utilized in microscale thermoelectric applications.

CsBi₄Te₆ shows a very wide temperature range, giving high values (>30 μ W/cm·K²) of power factor by different doping, from 109 K (39.0 μ W/cm·K² by 0.1% Sb) to 217 K (32.3 μ W/cm·K² by 0.2% Bi) for p-type materials, see Figures 5, 10, and 11 and Table 5. The ability to shift the ZT maximum over a range of 100 K is a positive feature for applications, and it is similar to that of bismuth telluride alloys. The only difference is CsBi₄Te₆ is active at lower temperatures. For efficient low-temperature thermoelectric devices using p-type CsBi₄Te₆, they can be fabricated as follows: (1) a high ZT n-type thermoelectric material such as the Bi/Sb alloys having a wide working temperature (80–200 K) and (2) possible n-type CsBi₄Te₆ materials if future studies succeed in improving ZT to levels comparable to those of the p-type materials.⁴²

Carrier Concentration and Mobility in CsBi₄Te₆. Hall effect measurements were performed to estimate the concentration and mobility of carriers. The room-temperature carrier concentrations (3×10^{18} to 10^{19} cm⁻³) measured for the 0.1% and 0.2% SbI₃-doped p-type CsBi₄Te₆ samples are only slightly less than the generally accepted optimal value ($\sim 10^{19}$ cm⁻³)⁴³ for thermoelectric applications, see Figure 12. Carrier concentra-

^{(41) (}a) Venkatasubramanian, R.; Siivola, E.; Colpitts, T.; O'Quinn, B. Nature 2001, 413, 597–602. (b) CeFe_{4-x}Co_xSb₁₂: Fleurial, J. P.; Borshchevsky, A.; Caillat, T.; Morelli, D. T.; Meisner, G. P. In Proceedings of the 15th International Conference on Thermoelectrics; Caillat, T., Ed.; IEEE: Piscataway, NJ, 1996; pp 91–95. (c) TAGS-85: Skrabek, E. A. Compositional Variations of TAGS-type Materials. Presented at the Fourth RTG Working Group Meeting, Daytona Beach, FL, March, 1973. (d) PbTe: Tritt, T. M. Science 1999, 283, 804–805. (e) SiGe: Vining, C. B. Modern Perspectives on Thermoelectrics and Related Materials. In Materials Research Society Symposium Proceedings; Allred, D. D., Vining, C. B., Slack, G. A., Eds.; Materials Research Society: Pittsburgh, PA, 1991; Vol. 234, p 95. (f) Wölfing, B.; Kloc, C.; Teubner, J.; Bucher, E. Phys. Rev. Lett. 2001, 86, 4350–4353.

⁽⁴²⁾ Currently, the temperature at maximum power factor for n-type materials is found around 125 K (21.9 μW/cm•K² by 0.5% Sn and 23.8 μW/cm•K² by 1.0% Te), see Table 5.

 ^{(43) (}a) Tritt, T. M. Mater. Res. Soc. Symp. Proc. 1997, 478, 25–35. (b) Wood,
 C. Rep. Prog. Phys. 1991, 51, 459–539. (c) Ioffe, A. F. Semiconductor Thermoelements and Thermoelectric Cooling; Inforsearch Ltd.: London, 1957.



Figure 11. ZT data of the best-known thermoelectric materials as a function of temperature. At the shaded region, $CsBi_4Te_6$ could be possibly available for thermoelectric applications.



Figure 12. Carrier concentration and hole mobility as a function of temperature for (a) 0.1% SbI₃-doped and (b) 0.2% SbI₃-doped CsBi₄Te₆ crystals.

tion was found to be weakly dependent on temperature and doping level, with values decreasing as the temperature was lowered and as the doping increased. For these samples, the carrier concentration data could be correlated with the power factor data, showing that the latter decreased as carrier concentration moved away from 10^{19} cm⁻³.

Hole mobilities calculated from the electrical conductivity and Hall data show exponentially decreasing mobility as the temperature increases. The hole mobilities in SbI₃-doped CsBi₄-Te₆ samples range between 700 and 1000 cm²/V·s at room temperature. These are significantly greater than those typically found in the optimized p-type Bi₂Te₃ alloy (\sim 380 cm²/V·s).⁴⁴ At low temperatures, the mobilities rise to >5000 cm²/V·s. The very high hole mobilities could be due to the one-dimensional structure character of CsBi₄Te₆ and the lack of atomic disorder in its crystal lattice.

For n-type materials, samples doped with Sn and Te were examined. 0.5% Sn-doped CsBi₄Te₆ was selected for Hall measurements on the basis of the maximum power factor of 21.9 μ W/cm²·K at 127 K. The carrier concentration varies from 1.2 × 10¹⁹ cm⁻³ at 22.4 K to 2.38 × 10¹⁹ cm⁻³ at 312 K, Figure 13a. At room temperature, the carrier concentration and mobility were 2.11 × 10¹⁹ cm⁻³ and 325 cm²/V·s, respectively. The mobility decreases as the temperature increases, varying from 4600 cm²/V·s at 22.4 K to 302 cm²/V·s at 312 K.

For 1.0% Te-doped CsBi₄Te₆, the carrier concentration and mobility showed temperature dependence similar to those of 0.5% Sn-doped material, see Figure 13b. The carrier concentration varied from 1.16 × 10¹⁹ to 1.48 × 10¹⁹ cm⁻³, and the mobility ranged from 5890 to 419 cm²/V·s in the temperature range of 27–267 K. The maximum power factor of 21.7 μ W/ cm²·K occurred at 123 K for this material with the carrier concentration of 1.20 × 10¹⁹ cm⁻³ and mobility of 1260 cm²/ V·s, both greater than the values of SbI₃-doped p-type materials. It is interesting to note that the maximum power factors achieved with 0.5% Sn- and 1.0% Te-doped materials are similar and occur at about the same low temperature, 127 and 123 K.

Thermal Conductivity and Thermoelectric Performance. Before a ZT estimation can be made for the optimized samples

⁽⁴⁴⁾ Süssmann, H.; Heiliger, W. Proc. Conf. Transport. in Compound Semiconductors; MLT: Halle, Germany, KTB series, 1982; p 100.



Figure 13. Carrier concentration and mobility as a function of temperature for (a) 0.5% Sn-doped and (b) 1.0% Te-doped CsBi₄Te₆ crystals.

of $CsBi_4Te_6$, reliable measurements of the thermal conductivity are needed. The rather complex and highly anisotropic crystal structure of $CsBi_4Te_6$ with the relatively large unit cell and heavy atoms is poised well to very high thermal resistance. This is because heavy atoms give rise to low acoustic phonon frequencies and the large unit cell and low symmetry generates relatively long and tortuous mean free paths in the structure. Therefore, a low thermal conductivity in this system can be expected.

The room-temperature thermal conductivities of oriented ingots of $CsBi_4Te_6$ measured along the *b*-axis are in the range of 1.25-1.85 W/m·K depending on the doping level, see Figure 14. These low values are comparable to ~1.6 W/m·K of $Bi_{2-x}Sb_xTe_{3-y}Se_y$ alloy. The thermal conductivity expresses a significant anisotropic feature of $CsBi_4Te_6$, showing that the value measured along the perpendicular direction to the needle axis (*b*-axis) of the crystal is only about one-third of that obtained from the parallel (major conduction) direction.

The temperature dependence of the total thermal conductivity is typical for a crystalline material showing a large peak at ~ 20 K which is due to the appearance of the Umklapp process as the temperature rises.⁴⁵ Over this temperature, heat-carrying phonons are involved in a number of collisions that begin to give rise to substantial thermal resistance that lowers the conductivity. At temperatures higher than ~ 50 K, the lattice thermal conductivity (κ_{latt}) is not sensitive to the presence of very low levels of impurities such as dopants. Impurities are very important in the low-temperature region below the Umklapp peak in the thermal conductivity. ARTICLES



Figure 14. Variable-temperature thermal conductivities for oriented ingots of (a) "as-prepared" and 0.05% SbI₃-doped CsBi₄Te₆ measured (b) parallel and (c) perpendicular to the needle (*b*-axis) direction of the sample. For comparison, thermal conductivity data for the (d) $Bi_{2-x}Sb_xTe_{3-y}Se_y$ alloy are shown.



Figure 15. Variable-temperature total thermal conductivity (κ) for 0.05% SbI₃-doped CsBi₄Te₆, and both the lattice (κ_1) and the electronic (κ_e) contribution as estimated from the Wideman–Franz law.

The electronic thermal conductivity (κ_{elec}) can be estimated by using the electrical conductivity data in conjunction with the Wiedemann–Franz law⁴⁶ (Lorenz constant of 2.45×10^{-8} W• Ω/K^2 was used). The lattice thermal conductivity (κ_{latt}) can then be extracted by subtracting κ_{elec} from κ_{total} . The lattice thermal conductivity of CsBi₄Te₆ was estimated to 0.87 W/m· K at room temperature, see Figure 15, which is about 50% of the total thermal conductivity. This value was consistently obtained from a wide variety of doped CsBi₄Te₆ samples with varying numbers of carrier concentration and is reasonable because it is lower than the corresponding one for the Bi₂Te₃ which is 1.1 W/m·K.⁴⁷ The lower κ_{latt} in CsBi₄Te₆ is attributed to the lower symmetry crystal structure (C2/m vis-à-vis R-3m), the larger unit cell, and the ternary (vis-à-vis binary) composition of the compound. In the case of Bi2Te3, a considerable suppression of the κ_{latt} can be achieved via solid solutions (e.g., Bi_{2-x}Sb_xTe₃, Bi₂Te_{3-y}Se_y). Similarly, in CsBi_{4-x}Sb_xTe₆, CsBi₄- $Te_{6-x}Se_x$, and $Cs_{1-x}Rb_xBi_4Te_6$, we expect a further decrease in κ_{latt} because the disordered atoms are expected to increase phonon scattering. Unfortunately, the range of x is more limited than in the Bi₂Te₃ system.

With a good assessment of the thermal conductivity at hand, the ZT of $CsBi_4Te_6$ samples was reasonably estimated. The ZT

⁽⁴⁵⁾ Kittel, C. Introduction to Solid State Physics, 7th ed.; John Wiley & Sons: New York, 1996; ps 135, 162.

⁽⁴⁶⁾ Kittel, C. Introduction to Solid State Physics, 7th ed.; John Wiley & Sons: New York, 1996; p 166.
(47) CRC Handbook of Thermoelectrics: Rowe D. M. Ed.: CRC Press: Boca.

⁽⁴⁷⁾ CRC Handbook of Thermoelectrics; Rowe, D. M., Ed.; CRC Press: Boca Raton, FL, 1995; pp 239, 429, 211 and references therein.



Figure 16. Comparison of ZT's for (a) 0.05% SbI_3 -doped $CsBi_4Te_6$ and (b) p-type $Bi_{2-x}Sb_xTe_3$ alloy.

values for the optimized p-type CsBi₄Te₆ and the commercial p-type $Bi_{2-r}Sb_rTe_3$ alloy are presented as a function of temperature in Figure 16. The highest ZT at present of 0.82 at 225 K for CsBi₄Te₆ was attained from 0.05% SbI₃-doped material. At room temperature, the ZT value is 0.65. The material with 0.06% Sb doped is also expected to have at least a comparable maximum ZT value to 0.82 of 0.05% SbI3-doped material based on a higher power factor of 0.06% Sb-doped material. In contrast, commercially available Bi_{2-x}Sb_xTe₃ maximizes the ZT value at 0.95 near room temperature and drops to 0.58⁴⁸ at the temperature where the SbI3-doped CsBi4Te6 shows its maximum ZT value of 0.82. Therefore, 0.05% SbI3-doped CsBi4Te6 is expected to reach optimum performance at approximately ~ 75 K below that possible for the optimized $Bi_{2-x}Sb_{x}Te_{3}$. This suggests that CsBi₄Te₆ would be superior for thermoelectric applications to $Bi_{2-x}Sb_xTe_3$ in the low-temperature region.

The estimated ZT values were obtained for the high power factor samples of BiI₃-, Sb-, and Bi-doped CsBi₄Te₆, see Figure 17. Interestingly, 0.05% SbI₃- and 0.06 Sb-doped CsBi₄Te₆ have the same temperature, 225 K of maximum ZT, and 0.3% BiI₃- and 0.1% Bi-doped CsBi₄Te₆ also show the same corresponding temperature, 204 K. At this temperature region, the corresponding ZT of Bi_{2-x}Sb_xTe₃ is only about 0.42, and therefore CsBi₄-Te₆ has the potential to outperform by ~100%. This is the lowest temperature we were able to achieve to date with our doping studies of this new material.

Electronic Band Structure of CsBi₄Te₆. Given the plethora of new charge-transport results presented above regarding both p-type and n-type doped samples of CsBi₄Te₆, the ability of this material to achieve high ZT values at low temperature justifies attempts to understand and rationalize the observed behavior in terms of its electronic band structure. Although a detailed band structure calculation has been published for CsBi₄-Te₆,¹⁸ here we will strive to make important links between the nature of the valence band maximum and the superiority of p-type samples and even speculate on the lack of comparable performance on behalf of the n-type samples and the corresponding nature of the conduction band.

Band structure calculations for CsBi₄Te₆ were performed without and with a spin-orbit coupling, see Figure 18. The spin-orbit coupling shifts the conduction band toward the



Figure 17. Variable-temperature ZT for (a) 0.05% SbI₃-doped CsBi₄Te₆ and for comparison the estimated ZT's for (b) 0.06% Sb-, (c) 0.3% BiI₃-, and (d) 0.1% Bi-doped sample.



Figure 18. Electronic band structure of CsBi₄Te₆, (a) before adding spin-orbit interaction and (b) after adding spin-orbit interaction.

valence band, resulting in an indirect gap of 0.04 eV placed between the Γ point in the valence band and a general point (C*) in the conduction band. Undoubtedly, CsBi₄Te₆ is a very narrow gap semiconductor. The band gap of CsBi₄Te₆ was observed spectroscopically in the far-infrared region to be ~0.1 eV, see Figure 19. This value agrees with the energy gap range of 0.04–0.08 eV obtained from the formula $E_g \approx 2S_{max} \cdot T_{max}^{49}$ using maximum thermopower and the temperature at maximum thermopower, based on the results of Figures 3 and 4. The band gap of Bi₂Te₃ is larger at 0.16 eV than that of CsBi₄Te₆. The

⁽⁴⁸⁾ Recent optimization work on p-type Bi_{2-x}Sb_xTe_{3-x}Se_y alloys reported a low-temperature ZT_{max} value of 0.64 at ~210 K: Vedernikov, M. V.; Kutasov, V. A.; Luk'yanova, L. N.; Konstantinov, P. P. Proceedings of the 16th International Conference on Thermoelectrics; IEEE: Piscataway, NJ, 1997; p 56.

⁽⁴⁹⁾ Goldsmid, H. J.; Sharp, J. W. J. Electron. Mater. 1999, 28, 869.



Figure 19. Infrared diffuse reflectance spectrum of CsBi₄Te₆. The energy gap is indicated in the spectrum.

energy gap of CsBi₄Te₆ calculated by electronic structure including spin-orbit interaction is also in good agreement with the value observed by angle resolved photoemission study.⁵⁰

There are two key questions one would like to address in the case of CsBi₄Te₆. First, why is this material better at low temperatures than Bi₂Te₃? Second, what is the origin of high power factor and good thermoelectric performance? The answers may be found in examining the electronic band structure in detail. In general, it is well accepted that the temperature of the ZT maximum in thermoelectric materials is a function of band gap size: the wider the band gap, the higher the temperature of maximum achievable ZT. This is understood in terms of carrier excitation from the valence to the conduction band with temperature. Excitation across the gap generates carriers of sign opposite to those that are responsible for the high thermopower. The extra carriers have opposite thermopower, which tends to decrease the overall value through cancellation. Wider band gaps delay the onset of carrier excitation across the gap, and the ZT maximum can be attained at higher temperatures. This explains the observed temperatures for maximum ZT for Bi₂Te₃, PbTe, and SiGe which are 300, 500, and 1200 K, respectively, and the order that mirrors the band gap size of 0.15, 0.25, and 0.7 eV. The observed band gap of $C_{s}Bi_{4}Te_{6}$ of only $\sim 0.08-0.1$ eV is the narrowest reported for a thermoelectric compound, and therefore it is not surprising that it performs best at low temperatures.

In general, when one moves from a binary semiconductor to a ternary one by introducing an alkali metal into its structure, the corresponding energy gap increases as the original structure is "broken down" and the overall dimensionality decreases. This is observed in almost every case with typical examples being CdS (2.4 eV) versus K₂Cd₃S₄ (3.0 eV),⁵¹ SnS₂ (2.15 eV) versus $A_2Sn_4S_9$ (A = K, Rb, Cs) (2.66 eV),⁵² and Bi₂Se₃ (0.32 eV) versus β -K₂Bi₈Se₁₃ (0.59 eV).⁶ It is then surprising and puzzling that a ternary compound such as CsBi₄Te₆ would possesses a more narrow band gap than Bi₂Te₃. The answer to this lies in the presence of the Bi-Bi bond created by introduction of Cs metal into Bi2Te3. A detailed band examination near the Fermi level indicates that a significant contribution exists from p-orbitals associated with the Bi atoms participating in the Bi-Bi bond. In the absence of such a bond as in Bi₂Te₃, the empty p-orbitals of Bi are destabilized and can rise higher in energy, opening the gap. The Bi-Bi bonds are expected to be weaker than the Bi-Te bonds and the corresponding p-orbitals are not empty, so the destabilization is not great, resulting in a narrow gap, despite the presence of the alkali metals in the structure. The presence of such homoatomic bonds in semiconductors in fact seems to have a similar band narrowing effect. For example, in those cases that pairs of compounds exist where one has a homoatomic bond and the other does not, a similar trend is observed. In GaSe (Ga-Ga bond) and Ga₂Se₃ (no Ga-Ga bond), the former has a band gap of 1.1 eV whereas the latter has a gap of 2.0 eV. The same is observed in BaGa₂Sb₂ (Ga-Ga bond, E_g 0.34 eV) and GaSb (no Ga–Ga bond, E_g 0.69 eV).53

The second question regarding the origin of high thermoelectric performance in CsBi₄Te₆ may be addressed from a detailed examination of the shape of the bands near the Fermi level. Although this has been discussed extensively in an earlier publication, here we just give the essence of what follows from the calculations to tie in the experimental results. The band structure shows multiple band minima in the conduction band along ΓZ and RV directions and a single band maximum at the Γ point in the valence band. This indicates that CsBi₄Te₆ may have a large ZT when it is doped by an electron-donor reagent (n-type) because the number of band minima is proportionally related to the carrier effective mass and thus contributes to the thermopower.

The most noteworthy feature in the electronic structure of CsBi₄Te₆ is that the compound has a significant anisotropy in carrier effective masses. The anisotropic effective mass influences the B parameter⁵⁴ that is a material parameter proportionally related to ZT, and is defined as follows:

$$B = \frac{1}{3\pi^2} \left[\frac{2k_{\rm B}T}{h^2} \right]^{3/2} \frac{\gamma \tau_x}{\kappa_1} \sqrt{\frac{m_y m_z}{m_x}} \tag{1}$$

where m_x , m_y , and m_z are the effective masses along three principal directions, m_x is the effective mass along the direction of the current flow, γ is the band degeneracy, τ_x is the scattering time, and κ_1 is the lattice thermal conductivity. It should be noted in eq 1 that m_x (the effective mass along the charge-transport direction) is inversely related to the parameter B. For an isotropic system where the effective masses along all three directions are similar, the *B* parameter will depend on only one of the effective masses (e.g., m_v) by cancellation of the other two (i.e., m_z/m_x). In contrast, for anisotropic system that the smallest effective masses are on the charge-transport direction x and one or both m_y and m_z are large, a large value of the B parameter can be expected. In the band structure of CsBi₄Te₆, along the direction (y) parallel to the Bi-Bi bonds, the carrier effective mass ($m_v = 1.16$) in the valence band is significantly higher than those in all other principal directions ($m_x = 0.02, m_z =$ 0.09 for the valence band, $m_x = 0.04$, $m_y = 0.47$, $m_z = 0.16$ for the conduction band). This implies that effective hole transport

⁽⁵⁰⁾ An angle-resolved photoemission study on the electronic structure of CsBi₄-Te₆ also showed 0.05 eV of energy gap: Greanya, V. A.; Tonjes, W. C.; Liu, R.; Olson, C. G.; Chung, D.-Y.; Kanatzidis, M. G. *Phys. Rev. B* 2002, 65 205123

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in the valence band takes place along the direction perpendicular to the crystal growth direction (crystallographic *b*-axis) in the plane of the Bi/Te slab, eventually leading to a tendency of $CsBi_4Te_6$ to be a p-type material. Also, Bi-Bi bonds play a significant role for a high ZT for $CsBi_4Te_6$.

Concluding Remarks

CsBi₄Te₆ is a promising new thermoelectric compound. The compound features a unique structure type with infinite [Bi₄-Te₆] rods that are parallel-linked via Bi-Bi bonds. Bi-Bi bonds are rarely found in bismuth chalcogenide chemistry. It is one of very few compounds known that can be doped to achieve a very high ZT value below room temperature. The combination of several important characteristics such as low crystal symmetry (monoclinic), high structural anisotropy, large electronic anisotropy, heavy atoms, and large unit cell results in a system with very low thermal conductivity and an electronic structure that favors the development of high power factors. Band calculations suggested that CsBi₄Te₆ has very advantageous electronic structural features for a promising thermoelectric material characterized by a great deal of anisotropic effective mass. The electrical conductivity and thermopower are directly attributed to the elaborate electronic structure of a material near the Fermi level. The presence of Bi-Bi bonds in the structure is responsible for the material having a very narrow energy gap, nearly one-half that of Bi₂Te₃. In the absence of such bonds, the ternary system would have had a higher energy gap. The narrower band gap is related to the fact that the ZT maximum in CsBi₄Te₆ is achieved at lower temperatures than in Bi₂Te₃. CsBi₄Te₆ is very responsive to the type and level of doping agents. Low doping levels appear to more significantly affect the charge-transport properties of CsBi₄Te₆. The maximum ZT value of 0.82 at 225 K was achieved by doping with 0.05% SbI₃, which is among the highest values ever reported below room temperature. Also, from the 0.3% BiI₃-, 0.1% Bi-, and 0.06% Sb-doped materials, significantly high power factors were achieved around 150 K which is even 30–40 K below the temperature for the maximum power factor for the 0.05% SbI₃doped material. This suggests that CsBi₄Te₆ may be useful for developing low-temperature thermoelectric devices and it could be adopted in a variety of applications with a wide range of working temperatures.

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Supporting Information Available: X-ray crystallographic files for $CsBi_4Te_6$ (CIF). This material is available free of charge via the Internet at http://pubs.acs.org.

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